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(54) **ALUMINUM OXIDE COATED CUTTING
TOOL AND METHOD OF MANUFACTURING
THEREOF**

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51/307; 51/309

(58) **Field of Classification Search**
None
See application file for complete search history.

(57) ABSTRACT

A body such as a cutting tool coated with refractory single- or multilayers, wherein specific layers are characterized by a controlled microstructure and phase composition with crystal planes preferably grown in a preferential direction with respect to the surface of the coated body. The coating includes one or several refractory layers of which at least one layer is a dense, fine-grained layer of $\alpha\text{-Al}_2\text{O}_3$ preferably textured in the (104) direction. The coated tool exhibits excellent surface finish and shows much improved wear and toughness properties compared to prior art objects when used for machining steel, cast iron and, particularly, when machining nodular cast iron.

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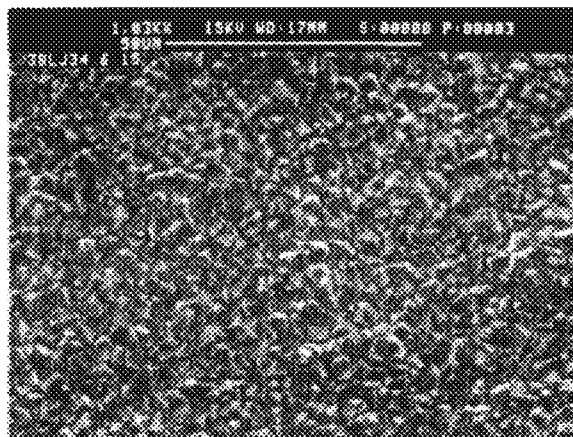
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REEXAMINATION RESULTS

The questions raised in reexamination proceedings Nos. 90/009,410, and 90/009,666, filed May 5, 2009, and Feb. 24, 2010 respectively, have been considered, and the results thereof are reflected in this reissue patent which constitutes the reexamination certificate required by 35 U.S.C. 307 as provided in 37 CFR 1.570(e) for *ex parte* reexaminations, and/or the reexamination certificate required by 35 U.S.C. 316 as provided in 37 CFR 1.997(e) for *inter partes* reexaminations.

29 Claims, 1 Drawing Sheet



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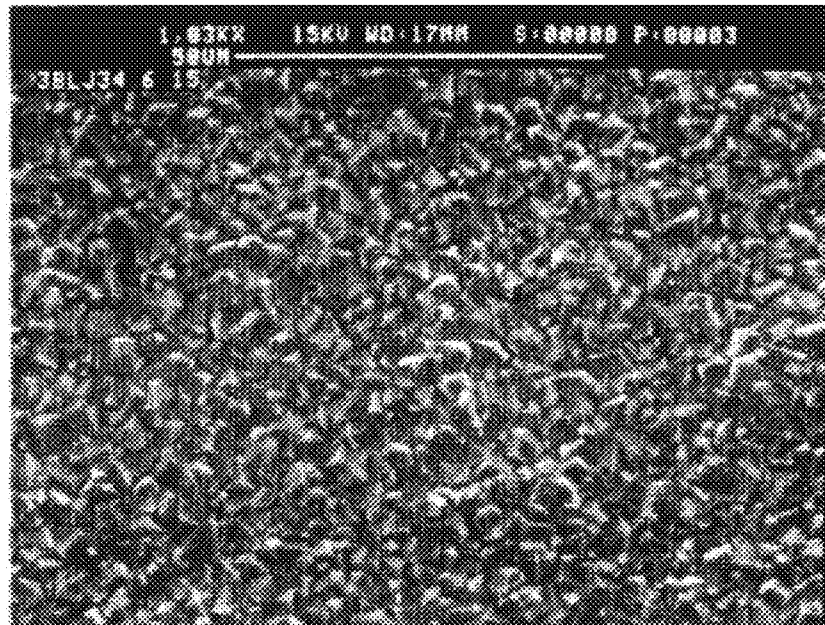
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ALUMINUM OXIDE COATED CUTTING TOOL AND METHOD OF MANUFACTURING THEREOF

Matter enclosed in heavy brackets [] appears in the original patent but forms no part of this reissue specification; matter printed in *italics* indicates the additions made by reissue.

CROSS-REFERENCE TO RELATED APPLICATIONS

The present application is a reissue of U.S. Pat. No. 5,766,782, which claims the benefit of priority to Swedish Application No. 9400089-0 filed Jan. 14, 1994.

FIELD OF THE INVENTION

The invention relates to a coated cutting tool for chip-forming machining, a method of making the tool and a method of machining metal with the tool.

BACKGROUND OF THE INVENTION

Chemical Vapour Deposition (CVD) of alumina on cutting tools has been an industrial practice for more than 15 years. The wear properties of Al_2O_3 as well as of other refractory materials have been discussed extensively in the literature.

The CVD-technique has also been used to produce coatings of other metal oxides, carbides and nitrides, the metal being selected from transition metals of the IVB, VB and VIB groups of the Periodic Table. Many of these compounds have found practical applications as wear resistant or protective coatings, but few have received as much attention as TiC, TiN and Al_2O_3 .

Cemented carbide cutting tools coated with various types of Al_2O_3 -coatings e.g., pure $\kappa\text{-Al}_2\text{O}_3$, mixtures of κ - and $\alpha\text{-Al}_2\text{O}_3$ and very coarse-grained $\alpha\text{-Al}_2\text{O}_3$ have been commercially available for many years. Al_2O_3 crystallizes in several different phases: α , κ , γ , β , θ , etc. The two most frequently occurring phases in CVD of wear resistant Al_2O_3 -coatings are the thermodynamically stable, hexagonal α -phase and the metastable κ -phase. Generally, the κ -phase is fine-grained with a grain size in the range 0.5-2.0 μm and often exhibits a columnar coating morphology. Furthermore, $\kappa\text{-Al}_2\text{O}_3$ coatings are free from crystallographic defects and free from micropores or voids.

The $\alpha\text{-Al}_2\text{O}_3$ grains are usually coarser with a grain size of 1-6 μm depending upon the deposition conditions. Porosity and crystallographic defects are in this case more common.

Often both α - and κ -phase are present in a CVD alumina coating deposited onto a cutting tool. In commercial cutting tools, Al_2O_3 is always applied on TiC coated carbide or ceramic substrates (see, e.g., U.S. Pat. No. 3,837,896, now U.S. Reissue Pat. No. 29,420) and therefore the interfacial chemical reactions between the TiC-surface and the alumina coating are of particular importance. In this context, the TiC layer should also be understood to include layers having the formula $\text{TiC}_x\text{N}_y\text{O}_z$ in which the carbon in TiC is completely or partly substituted by oxygen and/or nitrogen.

The practice of coating cemented carbide cutting tools with oxides to further increase their wear resistance is in itself well known as is evidenced in e.g., U.S. Reissue Pat. No. 29,420 and U.S. Pat. Nos. 4,399,168, 4,018,631, 4,490,191 and 4,463,033. These patents disclose oxide coated bodies and how different pretreatments e.g., of TiC-coated cemented

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carbide, enhance the adherence of the subsequently deposited oxide layer. Alumina coated bodies are further disclosed in U.S. Pat. Nos. 3,736,107, 5,071,696 and 5,137,774 wherein the Al_2O_3 layers comprise α , κ and/or $\alpha+\kappa$ combinations.

U.S. Pat. No. 4,619,866 to Smith describes a method for producing fast growing Al_2O_3 layers by utilizing a hydrolysis reaction of a metal halide under the influence of a dopant e.g., hydrogen sulphide (H_2S) in the concentration range 0.01-0.2% at a CVD deposition temperature of 1000-1050° C. Under these process conditions, essentially two phases of Al_2O_3 , the α and the κ phases, are produced. The resulting coating consists of a mixture of the smaller κ -grains and the larger α -grains. The process yields coatings with an even layer thickness distribution around the coated body.

Commonly owned Swedish Patent Application 9101953-9 (corresponding to U.S. patent application Ser. No. 07/902,721 filed Jun. 23, 1992, abandoned in favor of Ser. No. 08/238,341 filed May 5, 1994, the disclosures of which are hereby incorporated by reference) discloses a method of growing a fine-grained κ -alumina coating.

Commonly owned Swedish Patent Application No. 9203852-0 (corresponding to U.S. patent application Ser. No. 08/159,217 filed Nov. 30, 1993, the disclosure of which is hereby incorporated by reference) discloses a method for obtaining a fine-grained, (012)-textured $\alpha\text{-Al}_2\text{O}_3$ -coating. This particular Al_2O_3 -coating applied on cemented carbide tools has been found particularly useful for machining of cast iron.

Commonly owned Swedish Patent Application No. 9304283-6 discloses a body with a coating comprising one or more refractory layers of which at least one layer is a layer of $\alpha\text{-Al}_2\text{O}_3$ textured in the (110) direction. The alumina layer is essentially free of cooling cracks and comprises platelike grains with a length of 2-8 μm and a length/width-ratio of 1-10.

SUMMARY OF THE INVENTION

It is an object of this invention to avoid or alleviate the problems of the prior art.

It is also an object of this invention to provide an improved process for making coated bodies, the resulting coated bodies and methods for their use.

In one aspect of the invention there is provided a body such as a cutting tool insert at least partially coated with one or more refractory layers of which at least one layer is alumina, the alumina layer having a thickness of $d=0.5\text{-}25\text{ }\mu\text{m}$ with grain size (s): $0.5\text{ }\mu\text{m}<s<1\text{ }\mu\text{m}$ for $0.5\text{ }\mu\text{m}<d<2.5\text{ }\mu\text{m}$ and $0.5\text{ }\mu\text{m}<s<4\text{ }\mu\text{m}$ for $2.5\text{ }\mu\text{m}<d<25\text{ }\mu\text{m}$. The alumina layer consists of single phase α -structure textured in the (104)-direction with a texture coefficient larger than 1.5, the texture coefficient being defined as:

$$\text{TC}(\text{hkl}) = \frac{I(\text{hkl})}{I_o(\text{hkl})} \left\{ \frac{1}{n} \sum \frac{I(\text{hkl})}{I_o(\text{hkl})} \right\}^{-1}$$

where $I(\text{hkl})$ =measured intensity of the (hkl) reflection, $I_o(\text{hkl})$ =standard intensity of the ASTM standard powder pattern diffraction data, n =number of reflections used in the calculation and (hkl) reflections used are: (012), (104), (110), (113), (024), (116). The texture coefficient can be greater than 2.5, preferably greater than 3.0.

The alumina layer is preferably an exposed outermost layer. However, other layers can be present such as in the case where the alumina layer is in contact with a $\text{TiC}_x\text{N}_y\text{O}_z$ -layer.

The $\text{TiC}_x\text{N}_y\text{O}_z$ -layer can be an innermost layer of the coating. The body is preferably a cutting tool insert of cemented carbide, titanium based carbonitride or ceramics. The alumina layer can have a fine-grained microstructure of alumina grains with 80% or more of the alumina grains having a grain size of $\pm 50\%$ of an average grain size of the alumina layer. Also, the alumina layer can have a thickness of 4 to 8 μm and an average grain size of 1 to 3 μm .

The invention also provides a method of coating a body with an alumina coating, comprising steps of: contacting a body with a hydrogen carrier gas containing one or more halides of aluminum and a hydrolyzing and/or oxidizing agent at high temperature in a CVD-reactor atmosphere wherein oxidation potential of the reactor prior to nucleation of Al_2O_3 is kept at a low level by minimizing a total concentration of H_2O or other oxidizing species, carrying out nucleation of Al_2O_3 by controlled sequencing of reactant gases such that CO_2 and CO are supplied to the reactor first in an N_2 and/or Ar atmosphere followed by supplying H_2 and AlCl_3 to the reactor, the nucleation being carried out at a temperature between 850°C and 1100°C and carrying out growth of the Al_2O_3 by adding a sulphur dopant to the reactant gases. According to various features of the process, the dopant can comprise H_2S , the reactor temperature can be 950°C - 1000°C during the nucleation step, and prior to the nucleation of Al_2O_3 the concentration of H_2O or other oxidizing species in the hydrogen carrier gas is maintained below 5 ppm. Also, the body preferably comprises a cutting tool insert of cemented carbide, titanium based carbonitride or ceramics, wherein the alumina layer has a fine-grained single phase α -microstructure with 80% or more of the alumina grains having a grain size of $\pm 50\%$ of an average grain size of the alumina layer, the alumina layer having a thickness of 4 to 8 μm and an average grain size of 1-3 μm .

The coated body can be used for machining by contacting a metal workpiece with a cutting tool and moving the metal workpiece and the cutting tool relative to each other. The cutting tool comprises a body at least partially coated with one or more refractory layers of which at least one layer is alumina, the alumina layer having a thickness of $d=0.5\text{--}25\text{ }\mu\text{m}$ with grain size (s) wherein $0.5\text{ }\mu\text{m} < s < 1\text{ }\mu\text{m}$ for $0.5\text{ }\mu\text{m} < d < 2.5\text{ }\mu\text{m}$ and $0.5\text{ }\mu\text{m} < s < 4\text{ }\mu\text{m}$ for $2.5\text{ }\mu\text{m} < d < 25\text{ }\mu\text{m}$. The alumina layer consists of single phase α -microstructure textured in the (104)-direction with a texture coefficient larger than 1.5, the texture coefficient (TC) being defined as:

$$\text{TC}(\text{hkl}) = \frac{I(\text{hkl})}{I_o(\text{hkl})} \left\{ \frac{1}{n} \sum \frac{I(\text{hkl})}{I_o(\text{hkl})} \right\}^{-1}$$

where $I(\text{hkl})$ =measured intensity of the (hkl) reflection; $I_o(\text{hkl})$ =standard intensity of the ASTM standard powder pattern diffraction data; n=number of reflections used in the calculation and (hkl) reflections used are: (012), (104), (110), (113), (024), (116). The metal workpiece can comprise a steel, stainless steel, cast iron or nodular cast iron workpiece. The cutting tool insert can be of cemented carbide, titanium based carbonitride or ceramics and the alumina layer can have a fine-grained α -microstructure of alumina grains with 80% or more of the alumina grains having a grain size of $\pm 50\%$ of an average grain size of the alumina layer, the alumina layer having a thickness of 4 to 8 μm and an average grain size of 1 to 3 μm .

BRIEF DESCRIPTION OF THE DRAWINGS

FIG. 1 is a photomicrograph of an Al_2O_3 coating in accordance with the invention.

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

According to the invention there is provided a cutting tool comprising a body of a hard alloy onto which a wear resistant coating has been deposited. The coating comprises one or several refractory layers of which at least one layer is a dense, fine-grained and preferably textured Al_2O_3 -layer of the polymorph α . FIG. 1 shows a Scanning Electron Microscope (SEM) top-view micrograph at 1000X magnification of a typical Al_2O_3 -coating according to the invention.

A coated cutting tool according to the present invention exhibits improved wear and toughness properties compared to prior art tools when used for machining metal workpieces especially when the surface of the tool has been further smoothened by wet blasting. The alumina coated cutting tool insert provides improved cutting performance in machining steel, stainless steel, cast iron and nodular cast iron.

The invention also provides a method of applying onto a hard substrate or preferably onto a $\text{TiC}_x\text{N}_y\text{O}_z$ coating at least one single phase Al_2O_3 layer of the polymorph with a desired microstructure and crystallographic texture using suitable nucleation and growth conditions such that the properties of the Al_2O_3 layer are stabilized.

More specifically, the coated tool comprises a substrate of a sintered cemented carbide body, cermet or a ceramic body preferably of at least one metal carbide in a metal binder phase. The individual layers in the coating structure may be TiC or related carbide, nitride, carbonitride, oxycarbide and oxycarbonitride of a metal selected from the group consisting of metals in the Groups IVB, VB, and VIB of the Periodic Table, B, Al and Si and/or mixtures thereof. At least one of the layers is in contact with the substrate. However, at least one of the layers in the coating structure comprises a fine-grained, dense, single phase α - Al_2O_3 coating free of microporosity and crystallographic defects. This coating is preferentially textured with a thickness of $d=0.5\text{--}25\text{ }\mu\text{m}$ with an average grain size (s) of:

$$\begin{aligned} 0.5\text{ }\mu\text{m} < s < 1\text{ }\mu\text{m} & \text{ for } 0.5\text{ }\mu\text{m} < d < 2.5\text{ }\mu\text{m} \text{ and} \\ 0.5\text{ }\mu\text{m} < s < 4\text{ }\mu\text{m} & \text{ for } 2.5\text{ }\mu\text{m} < d < 25\text{ }\mu\text{m}. \end{aligned}$$

The fine-grained microstructure comprises a narrow grain size distribution. Most often 80% of the Al_2O_3 grains have a grain size of $\pm 50\%$ of the average grain-size.

The grain-size of the Al_2O_3 -coating is determined from a SEM top view micrograph at 5000X magnification. Drawing three straight lines in random directions, the average distances between grain boundaries along the lines, are taken as a measure of the grain-size.

The Al_2O_3 -layer according to the invention has a preferred crystal growth orientation in the (104) direction which is determined by X-ray Diffraction (XRD) measurements. A Texture Coefficient, TC, can be defined in the following calculation:

$$\text{TC}(\text{hkl}) = \frac{I(\text{hkl})}{I_o(\text{hkl})} \left\{ \frac{1}{n} \sum \frac{I(\text{hkl})}{I_o(\text{hkl})} \right\}^{-1}$$

where $I(\text{hkl})$ =measured intensity of the (hkl) reflection; $I_o(\text{hkl})$ =standard intensity of the ASTM standard powder pat-

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tern diffraction data; n=number of reflections used in the calculation and (hkl) reflections used are: (012), (104), (110), (113), (024), (116).

According to the invention TC for the set of (104) crystal planes is larger than 1.5, preferably larger than 2.5, and most preferably larger than 3.0.

The coated body according to the invention is further characterized by a surface roughness $[R]$ (R_a) of the refractory coating of less than 0.3 μm over a measured length of 0.25 μm mm. Preferably, the Al_2O_3 -layer is an exposed outermost layer.

The textured Al_2O_3 -coating according to the invention is obtained by careful control of the oxidation potential of the CVD-reactor atmosphere prior to the nucleation of Al_2O_3 . The total concentration level of H_2O or other oxidizing species should preferably be below 5 ppm. However, the nucleation of Al_2O_3 is initiated by a controlled sequencing of the reactant gases as follows: CO_2 and CO are first entering the reactor in a H_2 free atmosphere (e.g., in the presence of N_2 or/and Ar); then, a mixture of H_2 and AlCl_3 is allowed into the reactor. The temperature can be 850°C – 1100°C ., preferably 950°C – 1000°C ., during the nucleation. However, the exact conditions depend to a certain extent on the design of the equipment used. It is within the purview of the skilled artisan to determine whether the requisite texture and coating morphology have been obtained and to modify the nucleation and the deposition conditions in accordance with the present specification, if desired, to effect the amount of texture and coating morphology.

The following examples are provided to illustrate various aspects of the invention, it being understood that the same are intended only as illustrative and in nowise limitative.

EXAMPLE 1

Sample A

Cemented carbide cutting inserts with the composition 6.5% Co, 8.5% cubic carbides and balance WC were coated with a 5.5 μm thick layer of TiCN. In subsequent process steps during the same coating cycle, a 6 μm thick layer of $\alpha\text{-Al}_2\text{O}_3$ was deposited. Prior to the nucleation, the oxidation potential of the hydrogen carrier gas, i.e., the water vapour concentration, was set to a low level, less than 5 ppm. For instance, see U.S. Pat. No. 5,071,696, the disclosure of which is hereby incorporated by reference.

A hydrogen-free reaction gas mixture comprising N_2 , CO_2 and CO was first introduced into the CVD-reactor. The reaction gases were sequentially added in the given order. After a preset time, H_2 and AlCl_3 were allowed into the reactor. During the deposition of Al_2O_3 , H_2S was used as a dopant.

The gas mixtures and other process conditions during the Al_2O_3 deposition steps are set forth in Table 1.

TABLE 1

Process Condition	Step 1	Step 2
CO_2 :	4%	4%
AlCl_3 :	4%	4%
CO :	2%	—
H_2S	—	0.2%
HCl	1%	4%
H_2 :	balance	balance
Pressure:	55 mbar	100 mbar
Temperature:	1000°C .	1000°C .
Duration:	1 hr	7.5 hr.

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XRD-analysis of Sample A showed a texture coefficient, TC(104), of 3.2 of the (104) planes in the single in phase of the Al_2O_3 coating. SEM-studies of Sample A showed a fine-grained, 6 μm thick Al_2O_3 -coating with an average grain size of 2.1 μm .

Sample B

The cemented carbide substrate of Sample A was coated with TiCN (5.5 μm) and Al_2O_3 (6 μm) as set forth above except that the Al_2O_3 process was carried out according to a prior art technique resulting in a mixture of coarse α - and fine κ - Al_2O_3 grains in the coating.

Coated tool inserts from Samples A and B were all wet blasted with 150 mesh Al_2O_3 powder in order to smoothen the coating surface. The cutting inserts were then tested with respect to edge line and rake face flaking in a facing operation in nodular cast iron (AISI 60-40-18, DIN GGG40). The shape of the machined workpiece was such that the cutting edge is intermitted or impacted twice during each revolution.

Cutting data:

Speed=150 m/min.

Cutting Depth=2.0 mm and

Feed=0.1 mm/rev.

The inserts were run one cut over the face of the workpiece. The results are expressed in Table 2 as percentage of the edge line in cut that obtained flaking as well as the rake face area subjected to flaking in relation to total contact area between the rake face and the workpiece chip.

TABLE 2

Sample	Edge Line Flaking (%)	Rake Face Flaking (%)
A (invention)	5	6
B (comparative)	90	86

EXAMPLE 2

The cutting inserts from Samples A and B were also tested with respect to edge line flaking in a facing operation in an alloyed steel (AISI 1518, W-no. 10580). The shape of the machined workpiece was such that the cutting edge is intermitted or impacted three times during each revolution.

Cutting data:

Speed=130-220 m/min.

Cutting Depth=2 mm and

Feed=0.2 mm/rev.

The inserts were run one cut over the face of the workpiece. The results in Table 3 are expressed as percentages of the edge line in cut that obtained flaking.

TABLE 3

Sample	Edge Line Flaking (%)
A (invention)	0 (according to the invention)
B (comparative)	28

The foregoing has described the principles, preferred embodiments and modes of operation of the present invention. However, the invention should not be construed as being limited to the particular embodiments discussed. Thus, the above-described embodiments should be regarded as illustrative rather than restrictive, and it should be appreciated that variations may be made in those embodiments by workers

skilled in the art without departing from the scope of the present invention as defined by the following claims.

What is claimed is:

1. A body at least partially coated with one or more refractory layers of which at least one layer is alumina, said alumina layer having a thickness d of $0.5 \mu\text{m} \leq d \leq 25 \mu\text{m}$ with a grain size (s) of

$0.5 \mu\text{m} < s < 4 \mu\text{m}$;

said alumina layer consisting of single phase α -structure textured in the (104)-direction with a texture coefficient larger than [1.5] 2.5, the texture coefficient (TC) being defined by calculation:

$$TC(hkl) = \frac{I(hkl)}{I_0(hkl)} \left\{ \frac{1}{n} \sum \frac{I(hkl)}{I_0(hkl)} \right\}^{-1}$$

where

$I(hkl)$ =measured intensity of the (hkl) reflection

$I_0(hkl)$ =standard intensity of the ASTM standard powder pattern diffraction data

n =number of reflections used in the calculation and (hkl) reflections used are: (012), (104), (110), (113), (024), (116),

said alumina layer being an exposed outermost layer in contact with a $\text{TiC}_x\text{N}_y\text{O}_z$ -layer.

2. A body according to claim 1, wherein said $\text{TiC}_x\text{N}_y\text{O}_z$ -layer is an innermost layer of the coating.

3. A body according to claim 1, wherein said body is a cutting tool insert of cemented carbide, titanium based carbonitride or other ceramics.

[4. A body according to claim 1, wherein the texture coefficient is larger than 2.5.]

5. A body according to claim 1, wherein the texture coefficient is larger than 3.0.

6. A body according to claim 1, wherein the alumina layer has a fine-grained microstructure of alumina grains with 80% or more of the alumina grains having a grain size of $\pm 50\%$ of an average grain size of the alumina layer.

7. A body according to claim 1, wherein the alumina layer has a thickness of 4 to 8 μm and an average grain size of 1 to 3 μm .

8. The coated body of claim 1, wherein the alumina layer has been deposited by a chemical vapor deposition process wherein H_2S dopant is added to reactant gases during the deposition process.

9. The coated body of claim 1, wherein the alumina layer has been deposited during a chemical vapor deposition process wherein a sulfur dopant is added to reactant gases during the deposition process.

10. The coated body of claim 1, wherein the alumina layer has a surface roughness (R_a) of less than 0.3 μm over a measured length of 0.25 mm.

11. The coated body of claim 1, wherein the alumina layer has been smoothed by wet blasting.

12. The coated body of claim 1, wherein $0.5 \mu\text{m} < d < 2.5 \mu\text{m}$ and the grain size is greater than 0.5 μm and less than 1 μm .

13. The coated body of claim 1, wherein $2.5 \mu\text{m} < d < 25 \mu\text{m}$ and the grain size is greater than 0.5 μm and less than 4 μm .

14. The coated body of claim 1, wherein the texture coefficient is larger than 3.0 and the alumina layer has a fine-grained microstructure of alumina with 80% or more of the alumina grains having a grain size of $\pm 50\%$ of an average grain size of the alumina layer.

15. The coated body of claim 1, wherein the texture coefficient is larger than 3.0 and the alumina layer has a thickness d of $0.5 \mu\text{m} \leq d \leq 2.5 \mu\text{m}$ and the grain size is greater than 0.5 μm and less than 1 μm .

16. The coated body of claim 1, wherein the texture coefficient is larger than 3.0 and the alumina layer has a thickness d of $2.5 \mu\text{m} < d < 25 \mu\text{m}$ and the grain size is greater than 0.5 μm and less than 4 μm .

17. The coated body of claim 16, wherein said body is a cutting tool insert of cemented carbide, titanium based carbonitride or other ceramics.

18. A body at least partially coated with one or more refractory layers of which at least one layer is alumina, said alumina layer having a thickness 4 to 8 μm with an average grain size of 1 to 3 μm ,

said alumina layer consisting of single phase α -structure textured in the (104)-direction with a texture coefficient larger than 3.0, the texture coefficient (TC) being defined by calculation:

$$TC(hkl) = \frac{I(hkl)}{I_0(hkl)} \left\{ \frac{1}{n} \sum \frac{I(hkl)}{I_0(hkl)} \right\}^{-1}$$

where

$I(hkl)$ =measured intensity of the (hkl) reflection

$I_0(hkl)$ =standard intensity of the ASTM standard powder pattern diffraction data

n =number of reflections used in the calculation and (hkl) reflections used are: (012), (104), (110), (113), (024), (116),

wherein the alumina layer is an exposed outermost layer in contact with an inner $\text{TiC}_x\text{N}_y\text{O}_z$ -layer.

19. The coated body claim 18, wherein the alumina layer has been smoothed by wet blasting.

20. The coated body of claim 18, wherein the alumina layer has a fine-grained microstructure of alumina grains with 80% or more of the alumina grains having a grain size of $\pm 50\%$ of the average grain size of the alumina layer.

21. A body at least partially coated with one or more refractory layers of which at least one layer is alumina, said alumina layer having a thickness d of $0.5 \mu\text{m} \leq d \leq 25 \mu\text{m}$ with a grain size (s) of

$0.5 \mu\text{m} < s < 4 \mu\text{m}$;

said alumina layer consisting of single phase α -structure textured in the (104)-direction with a texture coefficient larger than 3.0, the texture coefficient (TC) being defined by calculation:

$$TC(hkl) = \frac{I(hkl)}{I_0(hkl)} \left\{ \frac{1}{n} \sum \frac{I(hkl)}{I_0(hkl)} \right\}^{-1}$$

where

$I(hkl)$ =measured intensity of the (hkl) reflection

$I_0(hkl)$ =standard intensity of the ASTM standard powder pattern diffraction data

n =number of reflections used in the calculation and (hkl) reflections used are: (012), (104), (110), (113), (024), (116),

said alumina layer being an exposed outermost layer in contact with an innermost $\text{TiC}_x\text{N}_y\text{O}_z$ -layer, and wherein the alumina layer has a fine-grained microstructure of alumina grains with 80% or more of the alumina grains having a grain size of $\pm 50\%$ of an average grain size of the alumina layer.

22. The coated body of claim 21, wherein the alumina layer has been smoothened by wet blasting.

23. A body at least partially coated with one or more refractory layers of which at least one layer is alumina, said alumina layer having a thickness d of $0.5\text{ }\mu\text{m} \leq d \leq 25\text{ }\mu\text{m}$ with a grain size (s) of

$$0.5\text{ }\mu\text{m} < s < 4\text{ }\mu\text{m};$$

said alumina layer consisting of single phase α -structure textured in the (104)-direction with a texture coefficient larger than 3.0, the texture coefficient (TC) being defined by calculation:

$$TC(hkl) = \frac{I(hkl)}{I_0(hkl)} \left\{ \frac{1}{n} \sum \frac{I(hkl)}{I_0(hkl)} \right\}^{-1}$$

where

$I(hkl)$ = measured intensity of the (hkl) reflection

$I_0(hkl)$ = standard intensity of the ASTM standard powder pattern diffraction data

n = number of reflections used in the calculation and (hkl) reflections used are: (012), (104), (110), (113), (024), (116),

said alumina layer being an exposed outermost layer in contact with a $\text{TiC}_x\text{N}_y\text{O}_z$ -layer,

wherein the alumina layer has been deposited by a chemical vapor deposition process wherein H_2S dopant is added to reactant gases during the deposition process.

24. The coated body of claim 23, wherein the $\text{TiC}_x\text{N}_y\text{O}_z$ -layer is an innermost layer.

25. The body according to claim 23, wherein said body is a cutting tool insert of cemented carbide, titanium based carbonitride or other ceramics.

26. The coated body of claim 23, wherein the texture coefficient is larger than 3.0 and the alumina layer has a fine-grained microstructure of alumina with 80% or more of the alumina grains having a grain size of $\pm 50\%$ of an average grain size of the alumina layer.

27. The coated body of claim 23, wherein the texture coefficient is larger than 3.0 and the alumina layer has a thickness d of $0.5\text{ }\mu\text{m} < d < 2.5\text{ }\mu\text{m}$ and the grain size is greater than $0.5\text{ }\mu\text{m}$ and less than $1\text{ }\mu\text{m}$.

28. The coated body of claim 23, wherein the texture coefficient is larger than 3.0 and the alumina layer has thickness d of $2.5\text{ }\mu\text{m} < d < 25\text{ }\mu\text{m}$ and the grain size is an $0.5\text{ }\mu\text{m}$ and less than $4\text{ }\mu\text{m}$.

29. The coated body of claim 23, wherein the alumina layer has been smoothened by wet blasting.

30. The coated body of claim 23, wherein the thickness of the alumina layer is 4 to $8\text{ }\mu\text{m}$ and an average grain size is 1 to $3\text{ }\mu\text{m}$.

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